

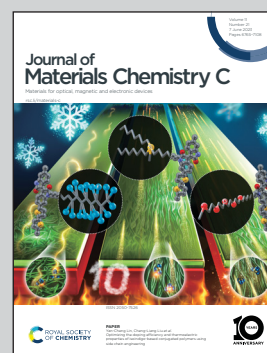


Showcasing research from the group of Prof. Woojin Jeon at Kyung Hee University, Rep. of Korea.

Enhancing chemisorption efficiency and thin-film characteristics *via* a discrete feeding method in high-*k* dielectric atomic layer deposition for preventing interfacial layer formation

The new utilization of discrete feeding method in atomic layer deposition was demonstrated for preventing the formation of an interfacial layer between the electrodes and insulator by increasing the chemisorption efficiency of precursors.

As featured in:



See Woojin Jeon *et al.*,
J. Mater. Chem. C, 2023, **11**, 6894.